

WEST[Help](#) [Logout](#) [Interrupt](#)[Main Menu](#) [Search Form](#) [Posting Counts](#) [Show S Numbers](#) [Edit S Numbers](#) [Preferences](#) [Cases](#)**Search Results -**

Terms	Documents
L18 and L17	89

Database:

- [US Patents Full Text Database](#)
- [US Pre-Grant Publication Full-Text Database](#)
- [JPO Abstracts Database](#)
- [EPO Abstracts Database](#)
- [Derwent World Patents Index](#)
- [IBM Technical Disclosure Bulletins](#)

Search:

L19

Refine Search

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Search History**DATE:** Saturday, April 06, 2002 [Printable Copy](#) [Create Case](#)

<u>Set Name</u>	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u>
side by side			result set

DB=USPT; PLUR=YES; OP=OR

<u>L19</u>	L18 and L17	89	<u>L19</u>
<u>L18</u>	((438/\$)!CCLS.)	45729	<u>L18</u>
<u>L17</u>	L16 and L8	191	<u>L17</u>
<u>L16</u>	L15 and L9	468	<u>L16</u>
<u>L15</u>	L14 and L10	1603	<u>L15</u>
<u>L14</u>	L13 and L12	5186	<u>L14</u>
<u>L13</u>	L1 and L11	153546	<u>L13</u>
<u>L12</u>	rins\$4 near5 water\$1	45242	<u>L12</u>
<u>L11</u>	remov\$4 or etch\$4	1592466	<u>L11</u>
<u>L10</u>	L4 or L5	198760	<u>L10</u>
<u>L9</u>	L2 or L3	35994	<u>L9</u>
<u>L8</u>	L6 or L7	125544	<u>L8</u>
<u>L7</u>	ozone	24631	<u>L7</u>
<u>L6</u>	"O.sub.3"	105700	<u>L6</u>
<u>L5</u>	HCl	111624	<u>L5</u>
<u>L4</u>	hydrochloric adj acid\$1	131262	<u>L4</u>
<u>L3</u>	"HF"	35970	<u>L3</u>
<u>L2</u>	hydrofluoric adj3 acid\$1	52	<u>L2</u>
<u>L1</u>	semiconduct\$4	246535	<u>L1</u>

END OF SEARCH HISTORY